

The Role of PEG 6000 and PVP as Stabilizing and Surfactant Agents in the Photoelectrochemical Properties of BiVO₄ Monoclinic Structure

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Nanocrystalline BiVO₄ on monoclinic phase was obtained by a modified-solution combustion synthesis (SCS) using poly(ethylene glycol) (PEG 6000) and polyvinylpyrrolidone (PVP) as stabilizing and surfactant agents, respectively. An active photoanode was built using a simple procedure by dip-coating deposition process on fluorine-doped tin dioxide (FTO). The structure, morphology and optical properties of FTO/BiVO₄ photoanode were evaluated by means of X-ray diffraction (XRD), Raman spectroscopy, scanning electron microscopy (SEM) and diffuse reflectance UV-Vis spectroscopy. The photoelectrochemical performance measurements were carried out by linear sweep voltammetry (LSV), chronoamperometry and electrochemical impedance spectroscopy (EIS) under InGaN blue light emitting diode (LED) illumination condition (about 450 nm). In Na₂SO₄ electrolyte solution, the electrode has presented better photoelectroactivity than in NaNO₃ solution, as evidenced by photoelectrochemical parameters such as: the highest photocurrent density (j_s) value, cathodic shifts of the onset potential (OP) and lower charge-transfer resistance (R_{ct}). In the methyl orange (MO) degradation reaction the FTO/BiVO₄ electrode has presented high photoelectroactivity, where the estimated kinetic constant rate (k_{obs}) is 4.74×10^{-3} and $7.54 \times 10^{-3} \text{ min}^{-1}$ in NaNO₃ and Na₂SO₄ solutions, respectively. This remarkable performance of the as-prepared electrode is due to the morphological BiVO₄ structure, with elongated-shape nano-sized domain particles, besides the considerable porosity and roughness levels on electrode surface.

Keywords: monoclinic BiVO₄, SCS, dip-coating process, PEG 6000, PVP, photoelectrochemical performance

Introduction

Monoclinic bismuth vanadate (BiVO₄) structure in the thin films configuration presents high technological potential, and may be used as electrode material, playing as photoanode in a wide range of systems.¹ In this context, some application stands out, such as: photocatalysis,^{2,3} water splitting involving the oxygen evolution reaction (OER)⁴⁻⁷ and photoelectrooxidation of a wide range of organic compounds in aqueous media, such as dyes,^{8,9} pesticides,¹⁰ antibiotics,^{11,12} and others.

In the last two decades, BiVO₄ has been highlighted as one of the most studied semiconductor material worldwide

by different research groups due to its unique properties.¹³ It has capability to absorb visible light for generation of charge carriers (electron-hole pairs), due to its narrow band gap energy in the order of 2.4 eV (energy within the visible range of the electromagnetic spectrum).^{1,13} This narrow band gap energy provides this semiconductor material the capability of using the solar light for excitation, which somewhat minimizes the cost of implementing certain devices where BiVO₄ acts as a photoanode.^{13,14} Another interesting feature of this semiconductor material is its high chemical stability in aqueous media, where it can be used repetitively numerous times in certain situations (several cycles of use) where corrosion is not observed or negligibly.^{3,15} This feature implies in reproducibility of data and long use, which is a very important parameter

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for technological application. In addition, BiVO_4 is a non-toxic material for human health, being an important factor towards its use.^{3,13-15}

The use of BiVO_4 thin films requires the designed device to have a conductive substrate due to the high electrical resistance of the semiconductor film itself.¹⁶ Conductive fluorine-doped tin dioxide (FTO) and indium tin oxide (ITO) substrates are widely used due to their low electrical resistance. The performance of photoanode, in this case the BiVO_4 film deposited on FTO or ITO conductive substrates, depends on several factors, such as: a good conductive substrate, the technique used to deposit the material in the form of film, the film deposition process and the electrolyte solution used.¹³ One of the techniques for obtaining this BiVO_4 material is the solution combustion synthesis (SCS) process, where the monoclinic phase of BiVO_4 is easily obtained with low cost during practicality the whole process.^{17,18} In this SCS process a bluish or greenish solution is obtained and by a dip-coating or spin coating process the film is deposited with controlled thickness, according to the required amount of layers and thickness.^{9,19} The SCS process has the advantage of being a fast, self-sustaining exothermic chemical reaction between metal salts and urea, which in this case acts as a process fuel, in addition to the use of a stabilizing agent, usually citric acid.¹⁶⁻¹⁸ Some modifications of the SCS process have been published.^{20,21} For example, in the paper of Serafim *et al.*,²⁰ the authors synthesized BiVO_4 nanoparticles by the SCS process using different fuels, urea, alanine and glycine. The results showed that when alanine was used as a fuel, a material with higher electroactivity in methylene blue photodegradation reaction was obtained.

The choice of electrolyte solution is also fundamental factor to the electroactivity of the BiVO_4 photoanode, because the electrolyte solution is directly related to the charge transfer kinetics at the photoanode/electrolyte interface.^{22,23}

In this context, the present paper proposes a photoelectrochemical performance evaluation of monoclinic BiVO_4 phase in the thin film configuration, obtained by the SCS/dip-coating process. The paper aims showing the role of poly(ethylene glycol) (PEG 6000) and polyvinylpyrrolidone (PVP) as stabilizing and surfactant agents, respectively, in the structural and morphological properties of obtained BiVO_4 material. The incorporation of these agents generated an enhancement in its photoelectrochemical activity. Along with the careful photoelectrochemical investigation, the performance of these electrodes face to the methyl orange (MO) electrochemical and photoelectrochemical degradation reaction was also analyzed.

Experimental

Materials and reagents

All used chemicals reagents are of analytical grade, produced by Sigma-Aldrich (São Paulo, SP, Brazil) and used without any further purification. The reagents are: poly(ethylene glycol) (PEG 6000; molecular weight (PM) = 5,400-6,600; impurities = 5 ppm of heavy metals), polyvinylpyrrolidone (PVP; PM = 40,000; purity level = 98%), bismuth nitrate hexahydrate ($\text{Bi}(\text{NO}_3)_3 \cdot 6\text{H}_2\text{O}$; purity level = 98%), nitric acid (HNO_3 ; purity level = 65-67%), ammonium hydroxide (NH_4OH ; 28-30% of NH_3), citric acid (purity level > 99%), urea (purity level = 99%), methyl orange (MO; purity level = 85%), acetone (purity level = 99.5%), sodium nitrate (NaNO_3 ; purity level = 99%) and sodium sulfate (Na_2SO_4 ; purity level = 99%). The solutions were prepared using ultrapure water (Sigma-Aldrich, São Paulo, SP, Brazil). Fluorine-doped tin oxide (FTO, resistivity (ρ) = $7 \Omega \text{ cm}^{-2}$) was used as conductor substrate. Dip-coating equipment was used for film deposition, as well the muffle furnace for the thermal annealing.

Synthesis of green-blue solution of BiVO_4 precursor and the construction of FTO/ BiVO_4 photoanode

The green-blue solution of BiVO_4 precursor was obtained by the solution combustion synthesis (SCS) process as described in previous published papers.^{9,16-18} Details on BiVO_4 synthesis, that include the steps of SCS procedure and also the amount of used reagents, can be seen in the Supplementary Information (SI) section in a schematic diagram (Figure S1). Particularly in the case of this paper, in addition to the citric acid used as a stabilizing agent, poly(ethylene glycol) (PEG 6000) was also used, unlike the mentioned papers that used only citric acid. Besides, polyvinylpyrrolidone (PVP) is also used in this synthesis process as surfactant. In the SCS process, urea act as fuel of self-sustaining chemical reaction. It will be shown in this paper that the combination of these two stabilizing agents, citric acid and PEG 6000, and by the action of the PVP as surfactant, provide better photoelectrochemical performance on FTO- BiVO_4 photoanode.

Four samples were obtained, which will be from now on called BiVO_4 (1), BiVO_4 (2), BiVO_4 (3) and BiVO_4 (4). The BiVO_4 (1) was obtained exactly how described in previous published papers,^{9,16-18} using citric acid as stabilizing agent, which is the typical conventional SCS process (Figure S1). For the BiVO_4 (2), BiVO_4 (3) and BiVO_4 (4), besides the citric acid, we have added PVP, PEG 6000 and PVP + PEG 6000,

respectively. For the BiVO_4 (2), 0.4 g of PVP was added in the first step of SCS synthesis along the bismuth precursor resulting in the solution called "solution A". In the second step of synthesis 0.2 g of PVP was added along the vanadium precursor resulting in the solution called "solution B". Finally, solutions A and B are mixed and left in muffle furnace at 90 °C for 20 h. After this time, a material with gelatinous consistency and green-blue color is obtained. We have chosen to keep the mass ratio (m/m) of PVP equal to the citric acid mass of the SCS process in each step. To obtain the BiVO_4 (3) the same procedure that was used to obtain BiVO_4 (2) is used, where the unique difference is that in the place of PVP, the PEG 6000 reagent in the same mass ratio of citric acid is added. Finally, to obtain the BiVO_4 (4) the same procedure that was used to obtain BiVO_4 (2) and BiVO_4 (3) is used. Here, PVP and PEG 6000 are added simultaneously to citric acid in the mass ratio (m/m) used above to the samples BiVO_4 (2) and BiVO_4 (3).

Before deposition of BiVO_4 onto fluorine-doped tin oxide (FTO, $\rho = 7 \Omega \text{ cm}^{-2}$), the substrate surface was cleaned in an ultrasonic bath using acetone for 30 min. After the cleaning procedure, the substrate was dried in muffle furnace at 100 °C for 1 h. Then, from the material with gelatinous consistency, an aqueous solution was obtained through dilution, and the FTO substrate was sequentially dipped inside this solution using the dip rate of 10 cm min^{-1} . Ten layers were deposited, and between each layer, the sample was dried for 10 min under room atmosphere conditions, followed by heating at 400 °C for another 10 min. After deposition deposited layers, the film is thermally annealed at 500 °C for 1 h.

Physical characterization

All samples were characterized by X-ray diffraction (XRD), Raman spectroscopy, diffuse reflectance and scanning electron microscopy (SEM). XRD measurements were carried out using a PANalytical diffractometer, model X'Pert PRO MPD (Malvern Panalytical Ltd), with the $\text{Cu K}\alpha$ (1.54056 Å) radiation, coupled to a nickel filter, with an applied tension of 40 kV and the current of 15 mA. The data are collected in 2 θ mode with 0.04 of step in the angular range of 10-80°. Raman scattering data were obtained through a Bruker FT, model Raman RFS 100 spectrometer (Bruker Corporation, Billerica, Massachusetts, USA), with excitation at 1,064 nm, obtained through the Nd:YAG laser with 200 mW power. Diffuse reflectance spectra were determined with the help of Shimadzu UV-3101 PC equipment (Shimadzu Scientific Instruments Inc., Maryland, USA) within the range 190-900 nm. SEM images were obtained in a Quanta

200-FEI microscope (FEI Company, Hillsboro, Oregon, USA) with 30 kV of applied voltage.

Photoelectrochemical measurements

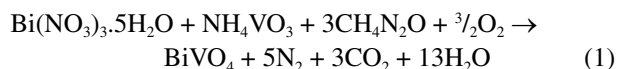
An electrochemical cell with three electrodes were used for the photoelectrochemical experiments, where an Ag/AgCl (3 mol L^{-1} KCl) electrode is the reference, a platinum wire is the counter electrode, and the BiVO_4 film as the working electrode (the geometrical electrode area in contact with the solution is set to 1.08 cm^2). A blue InGaN light emitting diode (LED) with average wavelength of 450 nm and average power of 15 mW was used as visible light source. The BiVO_4 surface illumination was accomplished from the sample front-side, with the light source positioned 5 cm distant from the film. The photoelectrochemical characterization procedures are carried out by linear sweep voltammetry (LSV), chronoamperometry and electrochemical impedance spectroscopy (EIS) techniques, through a potentiostat/galvanostat PalmSens, version 4, controlled by PSTrace 5 software, using 5 mL of 0.1 mol L^{-1} sodium nitrate (NaNO_3) and sodium sulfate (Na_2SO_4) as electrolyte solutions. In addition, for the EIS measurements the Nyquist and Bode plots were acquired at +1.4 V (vs. Ag/AgCl) with AC amplitude of 20 mV and frequency range of 0.05-100,000 Hz.

The performance test of methyl orange (MO) degradation reaction was carried out using 5 mL of 0.1 mmol L^{-1} of MO in 0.1 mol L^{-1} NaNO_3 and Na_2SO_4 electrolyte solutions. The electrolysis measurements were carried out by controlled potential of +0.8 V in different reaction time, in the dark and under illumination conditions (InGaN LED). After each electrolysis test, aliquots of solutions were collected, and the UV-Vis absorbance spectra were taken to verify the relative amount (percentage) of MO degraded. These spectra were obtained with the help of Shimadzu UV-3101 PC equipment.

Results and Discussion

Characterization of samples

The global chemical reaction of monoclinic BiVO_4 structure formation, using the SCS process, can be represented through reaction 1.²⁰



This reaction is characterized by a redox process, where the bismuth nitrate acts as oxidizing agent, while the urea fuel acts as reducing agent.^{17,18}

The amount of gases released during this process leads to heat dissipation, considering that the process is exothermic, keeping the system thermal stability.¹⁷⁻²⁰ The reagents citric acid and PEG 6000 does not show up in the reaction 1, since they act as stabilizing agents of Bi^{3+} and VO_3^- , avoiding the evaporation of these precursors during the whole synthesis process.²⁴ PVP also does not appear in equation 1 and, in addition to stabilizing agent role, it also plays a fundamental role as surfactant agent, acting as viscosity regulator in the solution.²⁵ Moreover, these stabilizing and surfactant agents help on the solution thermodynamic stability and may guide the particle morphology, and leads to nanometric dimensions structures.²⁶

Considering the influence of PEG 6000 $[\text{HO}(\text{C}_2\text{H}_4\text{O})_n\text{H}]$ in the SCS process, its stabilizing effect is related to its oxygen ions which accomplish strong coordination effect on Bi^{3+} and VO_3^- ions. Associated to this effect, the high amount of hydrogen bonds between the PEG 6000 and water creates the thermodynamic stability in the solution.^{24,26} For instance, Ribeiro *et al.*²⁴ report a BiVO_4 monoclinic Scheelite phase in the form of films, successfully obtained based on a quick one-step procedure employing different alcohol as solvents and stabilizing agents (ethanol, ethyleneglycol, PEG 300 and PEG 400). Different morphologies, crystal growth rate, crystallite sizes and thicknesses were obtained for the BiVO_4 films, depending on the type of precursor solvent, with significant effects on the photocurrents.

On the other hand, PVP $[(\text{C}_6\text{H}_9\text{NO})_n]$, besides playing as stabilizing agent of Bi^{3+} and VO_3^- ions (due to polarity effect of carbonyl group of PVP structure), also performs as dispersing agent, which influences the solution viscosity, through hydrogen interaction between PVP and water molecules.²⁵ Published reports^{25,27-31} have shown this double effect of PVP in the synthesis of a great variety of materials, such as BiVO_4 ,²⁵ $\text{Y}_2\text{O}_3:\text{Eu}^{3+}$,²⁷ $\text{Gd}_2\text{O}_2\text{S}:\text{Ln}^{3+}$ ($\text{Ln} = \text{Eu}, \text{Tb}$),²⁸ CdS ,²⁹ GdVO_4 ,³⁰ YVO_4 ,³¹ among others. Wang *et al.*²⁵ obtained BiVO_4 nanofibers and porous nanostructures by electrospinning method using PVP to adjust the viscosity and spinnability of the electrospinning sol. The results showed that the slow decomposition and combustion of PVP prevented rapid crystal growth of BiVO_4 , leading to structures with nano-size domain, besides preventing surface defects. In another work, Cui *et al.*²⁷ report a facile hydrothermal method to obtainment of monodispersed $\text{Y}_2\text{O}_3:\text{Eu}^{3+}$ colloidal spheres with controllable size (140-430 nm). According to the authors, the uniform and narrowly size-distributed $\text{Y}_2\text{O}_3:\text{Eu}^{3+}$ spheres are due to the PVP addition, that act as both surfactant and stabilizing agents.

In the present work, the electrode obtained in the synthesis process where PEG 6000 is used in conjunction

with PVP has presented the best electrochemical performance, as will be shown below. In this case, the added effect of PEG 6000-PVP has led to better species dispersion in the reaction media, along with stabilization of Bi^{3+} and VO_3^- ions, allowing morphological and structural control of the nanometric dimensions during the slow process of crystal growth, as can be seen by the SEM images shown below.

A proposed mechanism considering the jointly action of nitric acid, PEG 6000 and PVP in the formation of BiVO_4 crystals may be seen in SI section, Figure S2. Steps 1 and 2 correspond to the stabilization of Bi^{3+} and VO_3^- ions by nitric acid and PEG 6000, connected to dispersion of stabilized ions by PVP (this mechanism illustrates the obtainment of sample BiVO_4 (4)). A higher stabilization occurs due to the strong coordination of oxygen atoms in the PEG structure. Following these steps, a slower step (20 h, which is the synthesis time) takes place, where nucleation and BiVO_4 crystal growth in a PVP matrix occurs, keeping the particle dispersion. Finally, after the films deposition process and thermal annealing, the BiVO_4 monoclinic structure is obtained.

The diffraction patters of all samples (BiVO_4 (1), BiVO_4 (2), BiVO_4 (3) and BiVO_4 (4)) can be seen in Figure 1a. In all the samples the same diffraction peaks appears, at the same 2-theta position. The diffracted peaks marked by the symbol (\blacklozenge) belong to the BiVO_4 monoclinic structure as inferred from the PDF 75-1867 file of the PCPDFWIN software (version 2.4, JCPDS-ICDD). No peaks related to crystalline impurities or others BiVO_4 phases have been detected, indicating that the monoclinic BiVO_4 structure is highly dominant. This high purity level of the obtained material demonstrates that the synthesis process adopted here, SCS/dip-coating process, is highly efficient for obtainment of monoclinic BiVO_4 . Other diffracted peaks marked by the symbol (Δ) in Figure 1a belong to the FTO substrate ($\text{SnO}_2:\text{F}$ crystalline phase). A good evaluation of the average crystallite size of BiVO_4 material is done through the Scherrer formula³² using the (112) diffraction plane ($2\theta = 29^\circ$), which is the most intense. The values of average crystallite size can be seen in SI section (Table S1). These results show a slight variation in the average crystallite size between each sample.

Raman spectra for BiVO_4 films are shown in Figure 1b. The Raman shift of the most intense vibrational band is a little different for the samples BiVO_4 (1), BiVO_4 (2), BiVO_4 (3) and BiVO_4 (4), being the values 834, 833, 829 and 827 cm^{-1} , respectively, that corresponds to the shorter symmetric V–O stretching mode (A_g).³³ These values are in good agreement with literature, where for the BiVO_4 monoclinic phase the symmetric V–O stretching mode

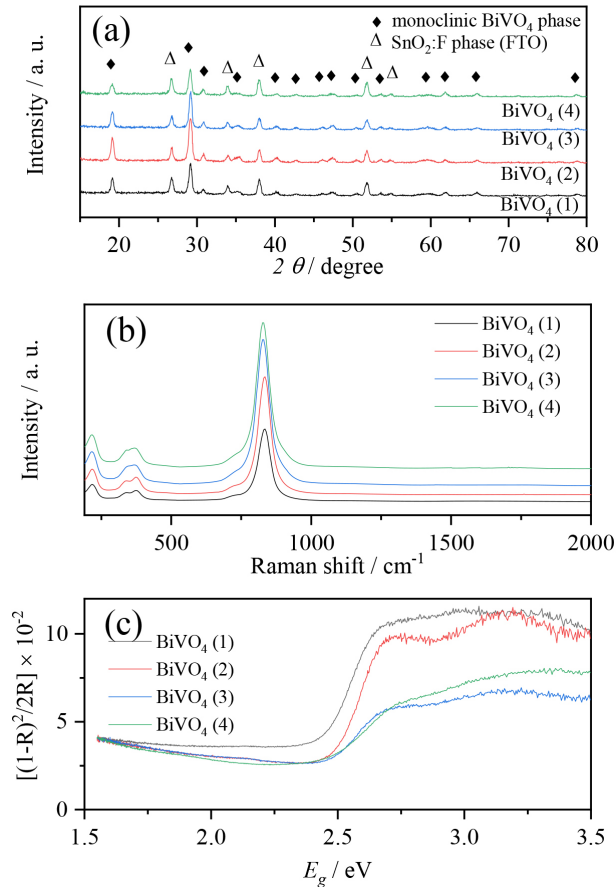


Figure 1. (a) XRD patterns, (b) Raman shift and (c) band gap evaluation (Kubelka-Munk model from UV-Vis diffuse reflectance) for BiVO₄ (1), BiVO₄ (2), BiVO₄ (3) and BiVO₄ (4) samples.

can appear in the range 826-832 cm⁻¹.^{33,34} The more intense Raman shift for BiVO₄ is located about 830 cm⁻¹, and this band location which can be used to obtain information on BiVO₄ crystalline structure. Then, using this intense vibrational band it is possible to obtain an estimative of the vanadium-oxygen bond length by equation 2, and as discussed in previously published works.^{24,35}

$$\nu_{V-O} \text{ (cm}^{-1}\text{)} = 21349 \times \exp[-1.9176 \times R_{V-O} \text{ (Å)}] \quad (2)$$

where ν_{V-O} is the symmetric V–O stretching mode (Ag) and R_{V-O} is the vanadium-oxygen bond length. Using this equation, the estimated values for the average V–O bond lengths obtained are 1.690, 1.691, 1.694 and 1.696 Å for the samples BiVO₄ (1), BiVO₄ (2), BiVO₄ (3) and BiVO₄ (4), respectively, (Table 1). These values are in good agreement with the reported values in a paper by Tokunaga *et al.*³⁶ (1.69 Å) and by Ribeiro *et al.*²⁴ (1.688 Å for BiVO₄/FTO-ethanol; 1.684 Å for BiVO₄/FTO-ethylene-glycol; 1.688 Å for BiVO₄/FTO-PEG300 and 1.689 Å for BiVO₄/FTO-PEG400), that gives the vanadium-oxygen bond length in the monoclinic crystal structure of BiVO₄

material. Other peaks are also observed, for instance, the weaker band at 717 cm⁻¹ corresponds to long (Ag) asymmetric V–O stretching mode.²⁴ Two peaks in the lowest wavenumber region at 337 and 375 cm⁻¹ are related to the asymmetric (Ag) and symmetric (Bg) deformations of VO₄³⁻ tetrahedron, respectively.^{33,34} It is also possible to identify a peak of about 215 cm⁻¹, which is associated to the external mode rotation/translation of BiVO₄ crystal.²⁴ In the range 1000 to 2000 cm⁻¹ no peak is observed, which is a good indication of the non-existence of carbon chemical species residues, that could be adsorbed on the samples, coming from the SCS process, related to combustion of organic compounds during the synthesis process.

Table 1. Band gap energy values and average V–O bond length of BiVO₄ films

Sample	Band gap energy / eV	R / Å
BiVO ₄ (1)	2.36	1.690
BiVO ₄ (2)	2.43	1.691
BiVO ₄ (3)	2.33	1.694
BiVO ₄ (4)	2.27	1.696

R: vanadium-oxygen bond length.

Figure 1c shows the band gap energy evaluation using the Kubelka-Munk model,³⁰ from the diffuse reflectance UV-Vis spectra of all obtained samples. The band gap energy (E_g) values were calculated using the equations 3 and 4.³⁰

$$\alpha = F(R) = \frac{(1-R)^2}{2R} \quad (3)$$

$$(\alpha h\nu)^2 = A (h\nu - E_g) \quad (4)$$

In these two equations, $F(R)$ is the Kubelka-Munk function, R is the absolute reflectance, α is the absorption coefficient, h is the Planck constant, ν is the frequency of light, A is a constant and E_g is the band gap energy. The obtained values of band gap energy are 2.36, 2.43, 2.33 and 2.27 eV for sample BiVO₄ (1), BiVO₄ (2), BiVO₄ (3) and BiVO₄ (4), respectively. These values are summarized in Table 1. Although a slight variation is observed between each sample, these band gap values are between 2.3 and 2.4 eV, in good agreement with previous published papers.^{16,17,37,38}

SEM topographic images of all the samples (BiVO₄ film deposited on FTO substrate) can be seen in Figure 2. The topographic image with magnification of 5000× shows the non-homogeneous surface to the BiVO₄ (1), BiVO₄ (2), BiVO₄ (3) and BiVO₄ (4) samples. Concerning images of BiVO₄ (1), BiVO₄ (2) and BiVO₄ (3) samples, it is possible

to observe some regions formed by particles with different sizes and with some micro aggregates, which in general, are quite similar. For the sample BiVO_4 (2) which was obtained using PVP as surfactant agent, a better dispersion of particles is observed, which can prove the action of PVP in the SCS process. In the sample BiVO_4 (3), the action of PEG 6000 as stabilizing agent is also evident, considering that the particles are smaller than particles of sample BiVO_4 (1) (obtained without PEG 6000). On the other hand, the combination of PEG 6000 and PVP has shown quite efficient as viewed in the SEM images for sample BiVO_4 (4).

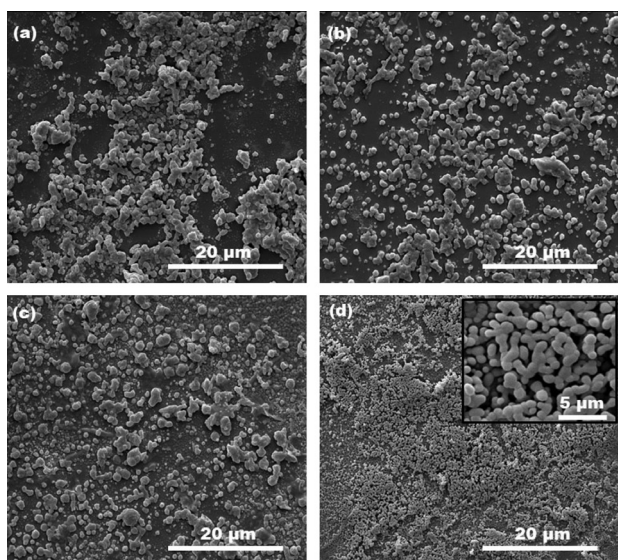


Figure 2. SEM surface images of (a) BiVO_4 (1), (b) BiVO_4 (2), (c) BiVO_4 (3) and (d) BiVO_4 (4) samples with magnification of 5000 \times . Inset in (d): magnification of 20000 \times .

Inserted image in Figure 2d shows the high level of dispersion and homogeneity in the particles distribution in all the analyzed area. The size of these particles is much smaller than particles of other three samples, besides the different shape, which in this case consists of particles with elongated shape, like rods, as observed by the inserted image in the top right corner of the respective image, with magnification of 20000 \times . In addition, the combination of PEG 6000 and PVP, as stabilizing and surfactant agents in the SCS process, provides also increase in the porosity and roughness levels in the sample, being quite interesting for the enhancement of photoelectrochemistry properties.

Photoelectrochemical characterization measurements

The linear sweep voltammetry (LSV) curves were obtained in three different experimental conditions: in dark, under continuous light illumination (light-on) and under

chopped light illumination (with 5 s light-on/light-off). The results of the electrode, using the BiVO_4 (4) sample, are shown in Figures 3a and 3b, in NaNO_3 and Na_2SO_4 electrolyte solution, respectively. Under continuous light illumination the photocurrent density increases with the anodic sweep potential (sweep to more positive potential, 0 to +1.4 V vs. Ag/AgCl) for both electrolyte solutions. Under chopped light illumination condition, it is possible to observe the reproducibility in the photocurrent density value. When the light is on, a jump of current is observed, and the reached current value is approximately the same obtained by continuous illumination. On the other hand, when the light is off, the current value is negligible, reached the same current value in dark condition (curve represented by dashed line). Then, this increase in the current density with the illumination of electrode shows the notable photoelectroactivity of this BiVO_4 (4) sample. At +1.2 V the photocurrent values are 0.06 and 0.182 mA cm^{-2} in NaNO_3 and Na_2SO_4 , respectively. This highest photocurrent density (j_s) value in Na_2SO_4 , approximately three times higher than NaNO_3 , must be associated with the fact of which this electrolyte solution favors the oxygen evolution reaction at photoanode/electrolyte interface.²³ Besides, the ionic strength may be a factor of contribution concerning

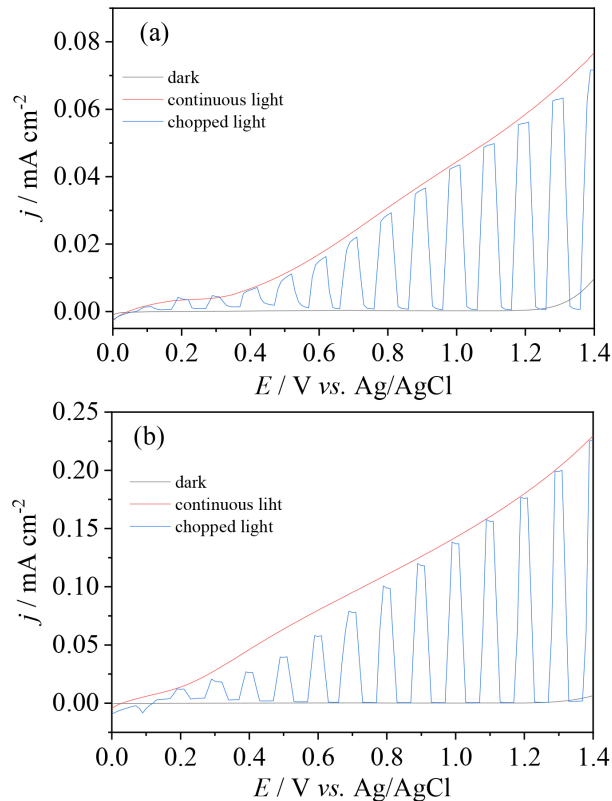


Figure 3. LSV curves at 10 mV s^{-1} scan rate, biased in the range 0 to +1.4 V vs. Ag/AgCl for BiVO_4 (4) sample in the dark, continuous and chopped light illumination under (a) NaNO_3 and (b) Na_2SO_4 solutions, both 0.1 mol L^{-1} .

more expressive photocurrent density values in Na_2SO_4 electrolyte solution. Others published works³⁹⁻⁴¹ report the use of Na_2SO_4 solution as efficient electrolyte solution in BiVO_4 photoanode in photoelectrochemical cells.

The sample BiVO_4 (4) has presented the better photoelectrochemical performance when compared to the other samples BiVO_4 (1), BiVO_4 (2) and BiVO_4 (3), in both NaNO_3 and Na_2SO_4 electrolyte solutions. The LSV curves of these other samples, in comparison with the LSV curve of BiVO_4 (4), can be seen in SI section, Figure S3. This comparison shows that the photocurrent density obtained by BiVO_4 (4) electrode is much higher than for the other samples. There is good indication that the better photoelectrochemical performance of BiVO_4 (4) is due to morphological and microstructural properties. Among all samples, the BiVO_4 (4) presents the narrowest band gap energy value, 2.27 eV as viewed in Table 1. Moreover, the Raman shift (Figure 1b), shows that the average V–O bond length evaluated for this sample is 1.696 Å, which is little larger than for the other samples, and may cause a relaxed state in this V–O bond, which favors the enhancement of the activity of oxygen evolution reaction.^{39,41} In addition, and maybe the most important parameter due to its direct relation with the photoelectrochemical properties, is the homogeneity distribution, which in the case of sample BiVO_4 (4) consists of particles with rods-shape format and nano-sized domain on the electrode surface, as can be seen in the SEM images in the Figure 2d. It is important to mention that the porosity and roughness levels on electrode surface are quite interesting for the enhancement of photoelectrochemistry properties.

The photochronoamperogram (j vs. t curves) of BiVO_4 (4) sample obtained under chopped light illumination (with 10 s period of alternating light-off/light-on), can be seen in Figure 4a in NaNO_3 and Na_2SO_4 solutions. The initial transient photocurrent decay (as observed from the j vs. t curve) which takes place immediately after the current reaches its maximum value upon illumination, was evaluated in order to obtain an understanding of the charge recombination behavior in the prepared FTO/ BiVO_4 electrode. When the light is on, the photocurrent density quickly reaches its maximum, however, this photocurrent density does not acquire stability, presenting a decay even before the light is turned off. This behavior in the shape of j vs. t curve can be associated to the fast electron/hole recombination process in the BiVO_4 semiconductor material, as already discussed in a previous report.⁴² In the NaNO_3 electrolyte solution, although the photocurrent density is lower than in Na_2SO_4 , the photocurrent signal seems to be more stable. The photochronoamperograms of other samples (BiVO_4 (1), BiVO_4 (2) and BiVO_4 (3)) are

shown in SI section, Figure S4. The decay profile of the j vs. t curves (Figure S4) are very similar as well as the behavior of photocurrent stability, and the photocurrent values at 100 s. The better photoelectrocatalytic performance of BiVO_4 (4) sample becomes evident from these photochronoamperograms curves. The photocurrent value is higher than for the other samples, as already observed from the LSV measurements.

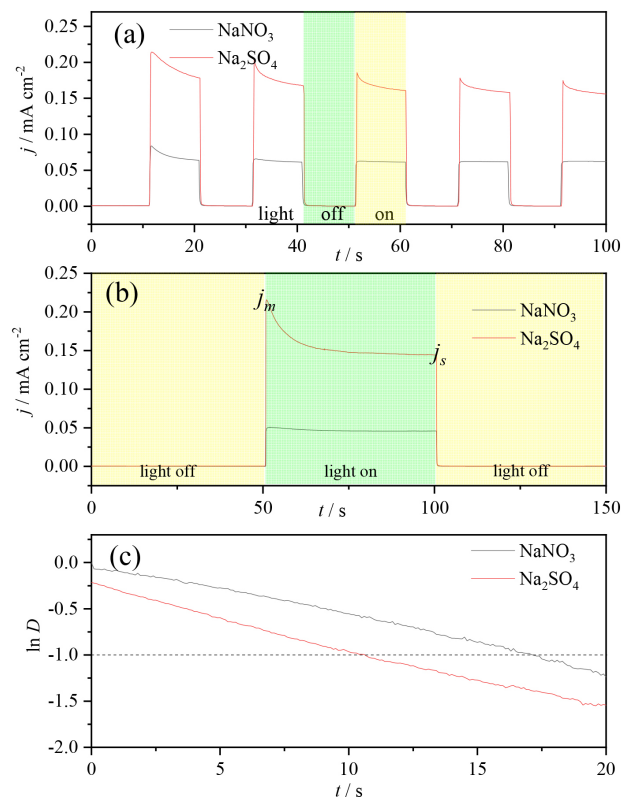


Figure 4. Photochronoamperogram of BiVO_4 (4) sample with an applied potential of +1.2 V vs. Ag/AgCl in 0.1 mol L^{-1} of different electrolyte solutions, NaNO_3 and Na_2SO_4 . (a) Chopped illumination condition with 10 s light-off/light-on until the time of 100 s. (b) Chopped illumination condition with 50 s light-off/light-on/light-off until the time of 150 s; (c) transient decay time (τ).

More photochronoamperometric measurements were carried out with a more prolonged time, aiming to obtain the estimated transient decay time (τ), which is a parameter associated with the lifetime of photogenerated electron-hole pairs in BiVO_4 . The results from this experiment is shown in Figure 4b, where the alternating steps of light-off/light-on/light-off were carried out with a period of 50 s. The shape profile of obtained photochronoamperogram curve is similar to the results displayed in Figure 4a, where immediately after the light-on the current reaches its maximum value, evidencing the photoelectroactivity of this electrode. This maximum current, called spike current (j_m), decreases as the chronoamperogram keeps running, until

reaching a current value with stable behavior, called stable current (j_s). Stable photocurrent (j_s) values for BiVO₄ (4) sample are 0.046 and 0.145 mA cm⁻² in NaNO₃ and Na₂SO₄, respectively. These values are summarized in Table 2, as well the j_s values of other samples (BiVO₄ (1), BiVO₄ (2) and BiVO₄ (3)). The photochronoamperograms of these other samples are shown in SI section, Figure S5.

Table 2. Stable photocurrent density (j_s) values obtained from photochronoamperogram (50 s light on-off) curves for all electrodes samples

Sample	j_s / (mA cm ⁻²)	
	NaNO ₃	Na ₂ SO ₄
BiVO ₄ (1)	0.0046	0.010
BiVO ₄ (2)	0.0064	0.020
BiVO ₄ (3)	0.0052	0.014
BiVO ₄ (4)	0.0460	0.145

The photochronoamperogram of Figure 4b can be further explored, by calculating the transient decay time (τ) of the electrode. As already mentioned, j_m is the current spike, the current value when the light is switched on, and j_s is the current density at the end of illumination time (the current density at the very moment where the recombination and charge generation reaches equilibrium). Figure 4c, which analyze the transient decay time (τ) of electron-hole pairs in the BiVO₄, gives more information on the charge carrier recombination process. This transient decay time was calculated from a logarithmic plot of parameter D, given by the equation 5.⁴³

$$\ln D = \frac{(j_t - j_s)}{(j_m - j_s)} \quad (5)$$

where j_t is the photocurrent at time t , the transient decay time is defined as the time at which $\ln D = -1$.⁴⁴⁻⁴⁷ The estimated values of decay time for the sample BiVO₄ (4) are 10.70 and 17.22 s in Na₂SO₄ and NaNO₃, respectively. These results show that in NaNO₃ solution the transient decay time (τ) is longer than in Na₂SO₄ electrolyte solution, suggesting a slight decrease of the charge recombination rate at the interface electrode/NaNO₃ electrolyte solution. From the transient decay profile (curve $\ln D$ vs. t), it is possible to observe a non-linear decay, indicating that the decay mechanism is rather complex, as mentioned in the paper of Bell *et al.*⁴³

In order to analyze the behavior of the LSV curve profile in potential range of 0 to +1.4 V in a condition which the photocurrent density seems to be stable, a steady-state experiment was performed. Steady-state

data were obtained in the same experimental setup in a photochronoamperometric way by registering the stable current (j_s) in each applied potential. The applied potential starting at zero and, with a step of 0.2 V reaches +1.4 V. To each applied potential, a corresponding photocurrent density value is obtained. The plot of j_p vs. E steady-state curves can be seen in Figures 5a and 5b, where the electrode is in NaNO₃ and Na₂SO₄ electrolyte solutions, respectively, along with the LSV curves (previously discussed in Figure 3). The profile of steady-state curves is similar to the LSV curves, in spite of the photocurrent density being a little lower. This lower photocurrent in steady-state condition was expected because the j_s values are obtained in the instant that the recombination and charge generation reaches equilibrium. Besides, the onset potential (OP) parameter is also evaluated. The OP is estimated as the potential where the photocurrent density start to increase, and the shifting of OP to more cathodic potential is an important parameter, defined as the photocurrent density to achieve highly efficient photoelectrochemical systems. The OP is related to the thermodynamic and kinetics processes at electrode surface/electrolyte solution.⁴⁷ A shift of 100 mV to more cathodic potential is observed in Na₂SO₄ solution compared to NaNO₃ solution, showing a better photoelectrochemical

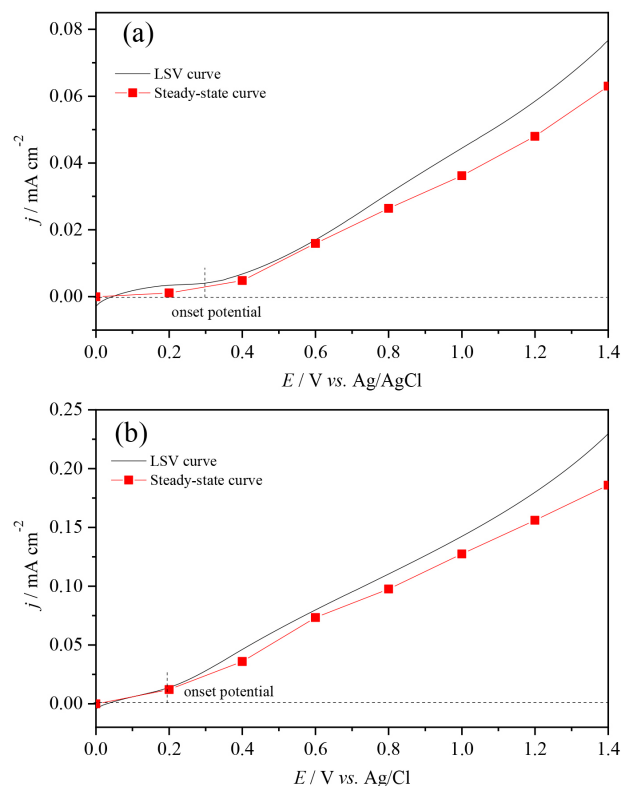


Figure 5. Steady-state polarization curves for BiVO₄ (4) sample in (a) NaNO₃ and (b) Na₂SO₄, both solutions 0.1 mol L⁻¹. The LSV curves are also shown for comparison.

performance in Na_2SO_4 solution, as already evidenced by the higher photocurrent density value.

Electrochemical impedance spectroscopy (EIS) measurements for the BiVO_4 (4) electrode are shown in Figure 6, being used to analyze the kinetics of charge transfer at the interface electrode/electrolyte solution. The measurements were carried out in the dark and continuous light illumination condition, through a simpler equivalent Randles-Ershler (R-E) model circuit,⁴⁸ modulated with three elements, R_s , R_{ct} and Q_1 . R_s accounts for the resistances of the FTO conductor electrode, the external electrical contacts of the system and the electrolyte solution.⁴⁹ R_{ct} is related to the direct charge-transfer resistance of BiVO_4 /electrolyte solution interface,⁶ and can be estimated from the semicircular Nyquist plot. Due the porosity level of the BiVO_4 film, as observed in the SEM image (Figure 2d), the Q_1 was used instead of common capacitance to take into account the frequency dispersion, as reported by Hernández *et al.*⁴⁹ and Dominguez-Benetton *et al.*⁵⁰

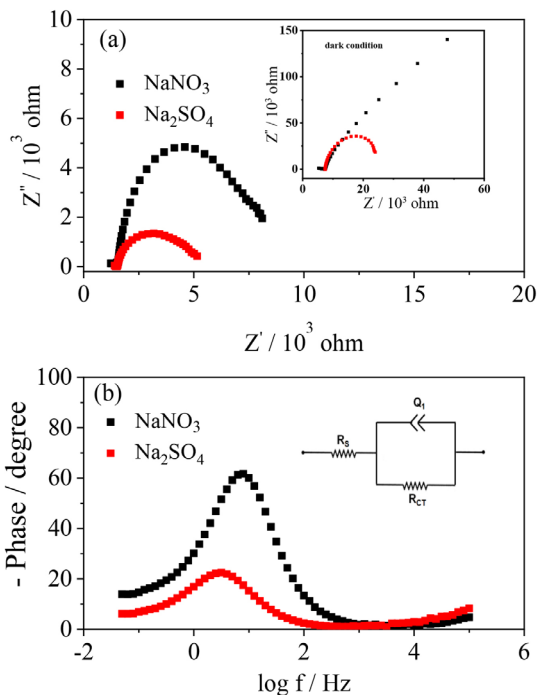


Figure 6. (a) Electrochemical impedance spectra of sample BiVO_4 (4) electrode under continuous illumination in NaNO_3 and Na_2SO_4 both 0.1 mol L^{-1} . The measurements were carried out with an applied potential of $+1.2 \text{ V vs. Ag/AgCl}$, AC amplitude of 20 mV and frequency range of $0.05\text{-}100,000 \text{ Hz}$. Inset: simple equivalent circuit used in these measurements and the impedance spectra in dark condition. (b) Bode plots of impedance spectra under light irradiation.

The effect of light incidence on charge-transfer resistance (R_{ct}) in the BiVO_4 semiconductor electrode is quite evident, when compared to the experiment in the dark condition. A smaller radius of the semicircle when the sample is placed under illumination leads to lower R_{ct} .

The R_{ct} values obtained in dark condition are 150×10^3 and $27 \times 10^3 \Omega$ in NaNO_3 and Na_2SO_4 , respectively. On the other hand, under illumination of the electrode, the R_{ct} estimated values are 9.2×10^3 and $5.3 \times 10^3 \Omega$ in NaNO_3 and Na_2SO_4 , respectively. These R_{ct} values are in good agreement with the results obtained through the LSV curves and chronoamperometry that show the high efficiency of the InGaN LED light source used here for electron-hole pair generation in BiVO_4 monoclinic structure.

Measurements leading to the Bode plots were also performed and are shown in Figure 6b where the Bode plot was obtained when the sample is under light illumination, in NaNO_3 and Na_2SO_4 solutions. From this diagram (phase angle vs. log frequency) one peak can be recognized, located at low frequency (below 1.5 Hz), which is associated with the charge transfer at BiVO_4 electrode/electrolyte solution interface.⁵¹ In this case, the shifting to lower log f value in the Na_2SO_4 electrolyte solution shows that this solution favors the charge transfer process at electrode/electrolyte interface. These Bode plots are in good agreement with the estimated R_{ct} value.

In addition, to contribute with a better understanding of the photoactivity performance enhancement of the BiVO_4 electrode, the flat band potential (E_{fb}) was estimated using Mott-Schottky (M-S) measurements. The E_{fb} estimated values were obtained by M-S equation,⁵² (equation 6).

$$\frac{1}{C^2} = \frac{2}{\epsilon q \epsilon_0 N_D A_{se}^2} \left(E - E_{fb} - \frac{k_b T}{q} \right) \quad (6)$$

where C is the capacitance of space charge region, ϵ is the relative permittivity of BiVO_4 (86),⁵³ ϵ_0 is the vacuum permittivity ($8.854 \times 10^{-12} \text{ F m}^{-1}$), q is the electron charge ($1.602 \times 10^{-19} \text{ C}$), A_{se} is the surface area of the electrode (cm^2), N_D is the charge carrier concentration (cm^{-3}), E is the applied potential (V vs. Ag/AgCl), E_{fb} is the flat band potential (V vs. Ag/AgCl), k_b is the Boltzmann's constant ($1.381 \times 10^{-23} \text{ J K}^{-1}$), and T is the temperature (298 K). Through the plot of $1/C^2$ vs. E , the intercept of the straight tangent line with the x axis in $1/C^2 = 0$ give us the estimated E_{fb} values.⁵²

The M-S measurements were carried out under dark condition in both 0.1 mol L^{-1} NaNO_3 and Na_2SO_4 solutions with an applied frequency of 100 Hz .

In the Figure 7 the M-S plot of BiVO_4 samples is shown, where it is possible to observe the positive slope of plot $1/C^2$ vs. E confirming the n-type conductivity of this material, meaning electrons are the majority charge carriers. The estimated E_{fb} values for all BiVO_4 samples can be seen in Table 3. In general, all of these E_{fb} estimated values are in good agreement with published

reports,⁵⁴⁻⁵⁹ using similar experimental conditions to these adopted in the present work, such as Na₂SO₄ electrolyte solution, pH condition in the range of 5-9, Ag/AgCl (KCl 3 mol L⁻¹) as reference electrode, 100-1000 Hz frequency applied range. For instance, some E_{fb} reported values such as -0.58 V vs. Ag/AgCl in 0.1 mol L⁻¹ Na₂SO₄,⁵⁵ -0.46 V vs. Ag/AgCl in 0.5 mol L⁻¹ Na₂SO₄,⁵⁶ -0.56 V vs. Ag/AgCl in 0.2 mol L⁻¹ Na₂SO₄,⁵⁷ -0.6 V vs. Ag/AgCl in 0.5 mol L⁻¹ Na₂SO₄,⁵⁸ are quite similar values to the ones obtained here, and listed in Table 3, ranging from -0.49 to -0.59 V vs. Ag/AgCl.

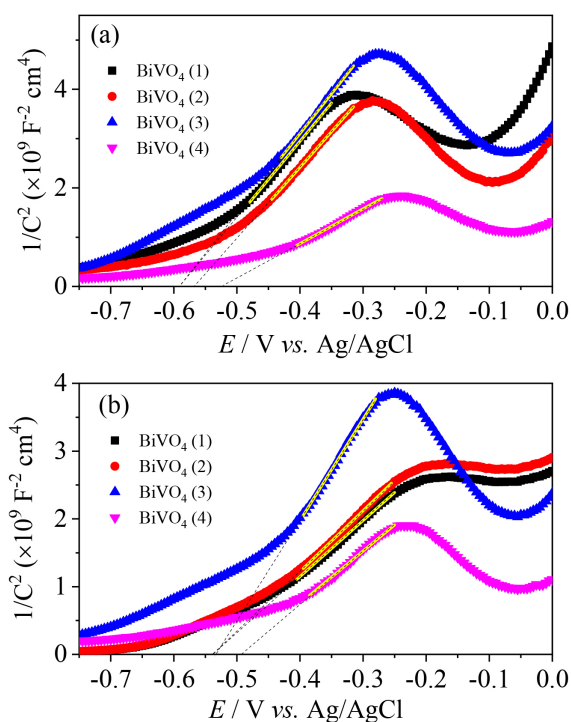


Figure 7. Mott-Schottky plots of BiVO₄ samples in different 0.1 mol L⁻¹ electrolyte solutions: (a) NaNO₃ and (b) Na₂SO₄. Applied frequency of 100 Hz.

Table 3. E_{fb} and N_D parameters obtained by M-S equation for BiVO₄ electrodes

Sample	NaNO ₃		Na ₂ SO ₄	
	E _{fb} / V	N _D / cm ³	E _{fb} / V	N _D / cm ³
BiVO ₄ (1)	-0.59	1.04 × 10 ¹⁸	-0.54	1.84 × 10 ¹⁸
BiVO ₄ (2)	-0.56	1.11 × 10 ¹⁸	-0.53	1.83 × 10 ¹⁸
BiVO ₄ (3)	-0.59	1.01 × 10 ¹⁸	-0.53	1.19 × 10 ¹⁸
BiVO ₄ (4)	-0.51	2.25 × 10 ¹⁸	-0.49	2.48 × 10 ¹⁸

N_D: charge carrier concentration; E_{fb}: flat band potential.

Based on these E_{fb} values, it is possible to affirm that the BiVO₄ (4) sample have presented a positive shift to more positive potential in both electrolyte solutions than the other samples, besides the lower slope in the linear region of M-S

curves. It is reported in the literature^{55,56,60} that the lower slope of the linear region of M-S curves has some direct relationship with the carrier density (N_D) in the bulk. In a way, this explanation is according with the estimated N_D values obtained for BiVO₄ (4), since this sample has presented higher N_D value than other samples. These estimated N_D values, which are also summarized in Table 3, were obtained by rearranging of M-S equation to equation 7,⁵² and using the slope of the linear portion of the curve.

$$N_D = \frac{2}{\epsilon q \epsilon_0 A_{se}^2} \left(\frac{dE}{d\left(\frac{1}{C^2}\right)} \right) \quad (7)$$

where, [dE/d(1/C²)] is the slope of linear region of curve. These N_D obtained values (10¹⁸ cm⁻³) are in good agreement with the others published papers using bare BiVO₄.^{61,62} In addition, considering the FTO/BiVO₄ (4) electrode, results related to others M-S measurements with different applied frequencies (100, 250 and 500 Hz) can be viewed in SI section, Figure S6. In general, a displacement in the E_{fb} of BiVO₄ towards more negative potential values is observed with the increase of applied frequency in both Na₂SO₄ and NaNO₃ electrolyte solutions.

Methyl orange photoelectrooxidation tests

Due to the remarkable photoelectrochemical (PEC) performance of BiVO₄ (4) electrode in both NaNO₃ and Na₂SO₄ electrolyte solutions, which has been explained based on the physical and photoelectrochemical characterization results, the BiVO₄ (4) sample was chosen to investigate the possible interaction of its surface face to the photoelectrochemical methyl orange (MO) degradation reaction. Some tests were carried out by cyclic voltammetry and chronoamperometry measurements using 5 mL of MO 0.1 mmol L⁻¹ plus 0.1 mol L⁻¹ of NaNO₃ and Na₂SO₄ as support electrolytes. Figure 8 shows the cyclic voltammograms in dark condition and under continuous light illumination. In the dark, it is possible to observe the electroactivity of this electrode in the MO oxidation, by comparing the cyclic voltammograms in absence (black line) and in the presence of MO (red line). In the NaNO₃ solution with the presence of MO two oxidation peaks are observed in the anodic scan, which are the peak I_a at 0.42 V and II_a at 0.8 V, while in the cathodic scan one reduction peak is observed at 0.25 V, named III_c. The anodic II_a peak is associated with irreversible redox reactions leading to cleavage of the azo bonds of MO.⁶³ The cathodic peak associated with the II_a anodic peak, forming the redox pair, does not appear in this voltammogram once this

cathodic peak is located at -0.3 V.⁶³ The peaks I_a and III_c correspond to the redox pair with semireversible behavior ($j_{Ia}/j_{IIIc} \neq 1$). This semireversible redox pair is associated with the formation of unstable amine products,^{64,65} oxidized at 0.42 V and reduced at 0.25 V. In the Na_2SO_4 solution with the presence of MO these same three peaks show up, however with a little shift in the I_a and III_c potential position. Under continuous light irradiation condition, these three peaks are also observed, which shows that the same electrochemical processes are taking place. Besides, under light illumination the faradaic current (anodic current), associated with the II_a peak, is higher than in dark condition, showing the light effect on electrode surface, leading to an enhancement in the electroactivity. The obtained behavior of MO cyclic voltammogram is in good agreement with previous published papers.⁶³⁻⁶⁶

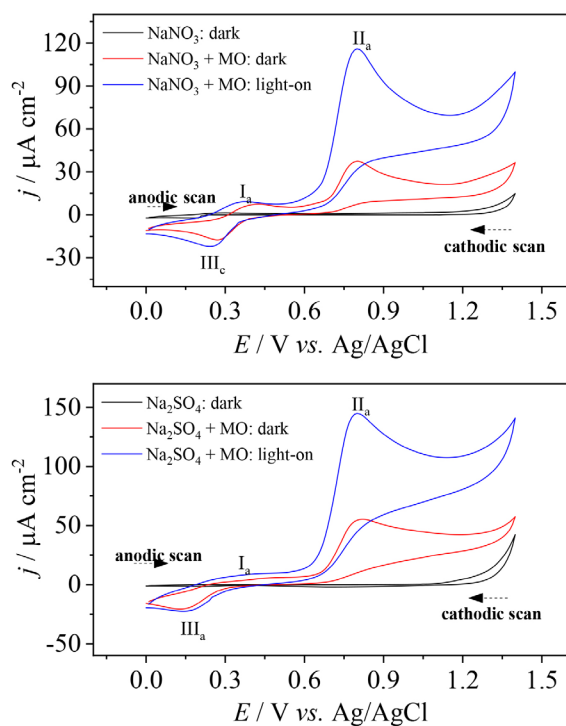


Figure 8. Cyclic voltammograms for $BiVO_4$ (4) sample in both 0.1 mol L^{-1} $NaNO_3$ and Na_2SO_4 solutions in absence and presence of MO 0.1 mmol L^{-1} . The experiment was carried out in the dark and under light illumination condition with sweep scan of 10 mV s^{-1} .

The MO degradation reaction was observed by carrying out chronoamperometric measurements in 0.1 mol L^{-1} $NaNO_3$ and Na_2SO_4 electrolyte solutions plus 0.1 mmol L^{-1} MO in different electrolysis time, under continuous light irradiation condition. Electrolysis experiments in the dark were also realized, aiming to verify the light effect in MO degradation. The applied potential chosen for electrolysis was $+0.8 \text{ V vs. Ag/AgCl}$, which is the potential where the MO electrooxidation occurs, as viewed in Figure 8

and discussed earlier. The UV-Vis absorbance spectra of degraded MO under continuous light illumination are shown in Figures 9a and 9b, in $NaNO_3$ and Na_2SO_4 solutions, respectively, as well the dark condition experiment (inset). In spite of the short electrolysis time, 60 min, the electrode was quite efficient in MO degradation reaction, as can be seen by the decrease in absorbance at about 453 nm . The light effect in the MO degradation reaction using the FTO/ $BiVO_4$ (4) electrode is quite evident when compared with the dark condition.

The degradation rate of MO is summarized in Figure 9c, where the C_t/C_0 profile as function of time shows the decrease of the 453 nm absorption band of MO, as already mentioned. Through this C_t/C_0 curve, applying the natural logarithm $\ln(C_t/C_0)$, Figure 9d, and make a plot of $\ln(C_t/C_0)$ vs. t , a linear behavior is observed, that suggest a pseudo-first-order kinetics model. Then, the pseudo-first-order rate constants (k_{obs}) were calculated from the slopes of $\ln(C_t/C_0)$ vs. t , according to equation 8:

$$\ln\left(\frac{C_0}{C_t}\right) = k_{obs} t \quad (8)$$

where C_0 and C_t are initial concentration and the concentration in the time t , respectively, t is the electrolysis time and k_{obs} is the kinetic constant rate. The k_{obs} obtained values under light condition are 4.74×10^{-3} and $7.54 \times 10^{-3} \text{ min}^{-1}$ in $NaNO_3$ and Na_2SO_4 solutions, respectively, which are higher than dark condition (1.43×10^{-3} and $1.14 \times 10^{-3} \text{ min}^{-1}$ in $NaNO_3$ and Na_2SO_4 solutions, respectively). These results using the FTO/ $BiVO_4$ (4) sample electrode, are in good agreement with reported results⁶⁷⁻⁷² and in comparison with some cases,^{67,69-72} the present results have presented better MO photoelectrodegradation efficiency.

For instance, the paper by Jiang *et al.*⁶⁹ has evaluated the morphology-dependent photocatalytic performance of $BiVO_4$ material for MO degradation under visible light illumination condition. Using the same monoclinic $BiVO_4$ structure with porous spherical particle shape as surface morphology and surface area of $1.4 \text{ m}^2 \text{ g}^{-1}$, their material reached a degradation percentage of 44% of MO solution in the prolonged time of 4 h. In the present work, the FTO/ $BiVO_4$ (4) electrode reached 42% of MO degradation in Na_2SO_4 electrolyte in a shorter time (only 60 min). In another paper, Wang *et al.*⁷¹ have evaluated the MO degradation reaction using bare $BiVO_4$ and with co-doping by boron and europium, synthesized by the sol-gel method. The authors have obtained the k_{obs} values of 3.7×10^{-3} , 7.1×10^{-3} and $11.3 \times 10^{-3} \text{ min}^{-1}$ for bare $BiVO_4$, B- $BiVO_4$ and 0.3Eu-B- $BiVO_4$, respectively, in the degradation time of 60 min. In the present paper, the k_{obs}

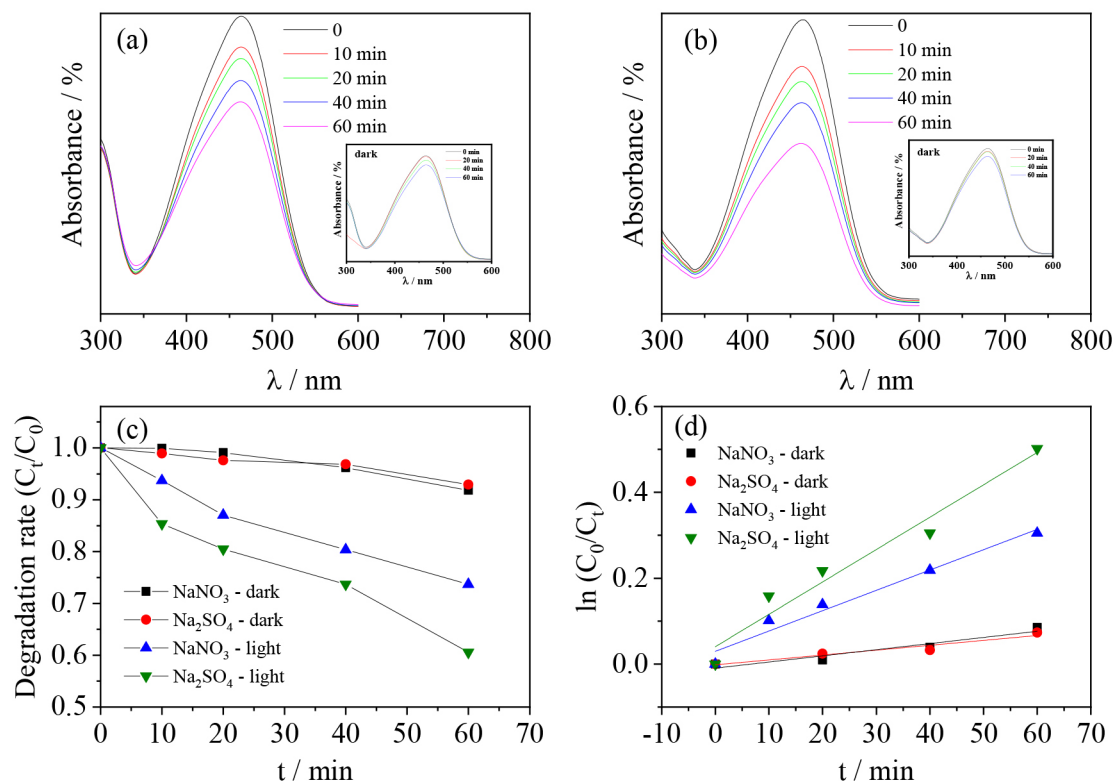
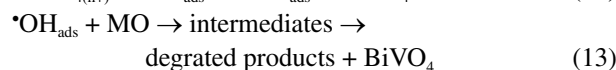
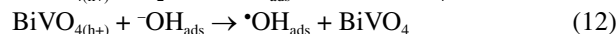
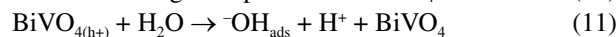
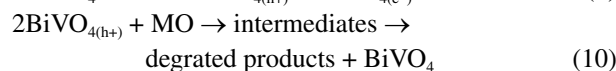
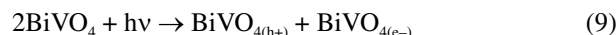


Figure 9. UV-Vis absorbance spectra of degraded MO in (a) NaNO₃ and (b) Na₂SO₄ electrolyte solutions under continuous illumination condition. Inset: degradation in dark condition. (c) Change in the MO concentration under photoelectrolysis measurements. (d) Kinetic curves of the MO degradation reaction.

results obtained are 4.74×10^{-3} and $7.54 \times 10^{-3} \text{ min}^{-1}$, which are higher values than bare BiVO₄ and B-BiVO₄ reported by Wang *et al.*,⁷¹ and slightly lower than 0.3Eu-B-BiVO₄. In another paper, Wang *et al.*⁷² have evaluated the MO degradation reaction using bare BiVO₄ and with co-doping by boron and lanthanum, synthesized by sol-gel method. The authors have obtained the k_{obs} values of 4.0×10^{-3} , 7.0×10^{-3} and $8.0 \times 10^{-3} \text{ min}^{-1}$ for bare BiVO₄, B-BiVO₄ and 0.01 La-B-BiVO₄, respectively, in the degradation time of 60 min. In comparison with the present paper, the k_{obs} results obtained here are higher than bare BiVO₄ and B-BiVO₄ k_{obs} values and almost the same value of 0.01 La-B-BiVO₄.

This remarkable photoelectrochemical performance in the MO degradation reaction under visible light illumination by FTO/BiVO₄ (4) electrode is due to its morphological structure, with shape-elongated nano-size domain particles and considerable porosity and roughness levels on electrode surface, besides its narrow band gap energy (2.5 eV). Then, taking into account these properties under visible light excitation, a high carrier density is generated on BiVO₄ material. With the help of an applied external potential in the electrochemical system, the photogenerated electrons (e⁻) which are promoted to the conduction band of BiVO₄ are immediately injected in the counter-electrode (platinum wire). On the other hand, the photogenerated holes (h⁺) in the valence band are free

to react on electrode surface. These free holes density photogenerated on BiVO₄ electrode surface are the key to an efficient MO demineralization reaction. A simplified MO photoelectrodegradation reaction mechanism on BiVO₄ surface, based in paper of Garza-Galván *et al.*⁷³ is proposed below, by two-pathway reaction sequence, the direct MO degradation (reaction 9 and 10) and MO degradation via ·OH-type radicals (reactions 9, 11-13) as follows:



A more efficient pathway of MO demineralization reaction is obtained through the ·OH-type radicals adsorbed on BiVO₄ surface, attacking the aromatic rings of MO molecules and leading to the degradation.

Conclusions

In summary, the results have shown that the combination of PEG-600 and PVP in the SCS process, acting as

stabilizing and surfactant agents, respectively, is quite efficient in obtaining monoclinic BiVO₄ phase with high photoelectroactivity. No evidence of impurities or secondary crystalline phase in the BiVO₄ samples was observed, from the characterization measurements carried out. The photoelectrochemical parameters, such as photocurrent density (j_s), onset potential (OP), transient decay time (τ), charge-transfer resistance (R_{ct}), flat band potential (E_{fb}) and carrier density (N_D) revealed the remarkable PEC performance of the as-prepared BiVO₄ electrode (sample BiVO₄ (4)).

In addition, in the methyl orange (MO) degradation reaction the FTO/BiVO₄ (4) electrode have presented high photoelectroactivity, where the estimated kinetic constant rate (k_{obs}) is 4.74×10^{-3} and $7.54 \times 10^{-3} \text{ min}^{-1}$ in NaNO₃ and Na₂SO₄ solutions, respectively.

These exciting results can be related to the morphological BiVO₄ surface structure, consisting of elongated-shaped particles in the nano-sized domain, besides the considerable porosity and roughness levels on electrode surface. These results highlight the potential application of monoclinic BiVO₄ obtained by the SCS/dip-coating process, as active electrode material for multifunctional photoelectrochemical system.

Supplementary Information

Supplementary information (Table S1 and Figures S1-S6) is available free of charge at <http://jbcs.s bq.org.br> as PDF file.

Acknowledgments

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